

## Patent Statement and Licensing Declaration Form for an Ecma International Standard



Patent Statement and Licensing
Declaration for an Ecma
International Standard
Version 1 (approved Dec. 2009)

This declaration does not represent an implied license grant

Please return to the Ecma Secretariat as instructed below per document type:

Secretary General
Ecma International
Rue du Rhône 114
CH-1204 Geneva
Switzerland

Patent Holder/O				
Legal Name	Amethystum Storage Technology Co.,Ltd.			
Contact for licen	se application:			
Name & Department	DODD CII 1 - markin Data Stancas			
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URL (optional)	www.amethystum.com/			
Document type:				
<b>ECMA</b> Stand	ard (*)			
(*)Number	Ecma/TC31/<2023>/021			
(*)Title	Holographic Data Storage Disk (HDSD) – Capacity: 1 Tbytes per disk			
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Organizatio	on	Amethystum Storage Technology Co.,Ltd.
Name of au	authorized Person Hu Dejiao	
Title of aut	thorized person	Manager
Signature		Hu Dejiao  Guangzhou China, 19 April 2023
Place, Date	9	Guangzhou China, 19 April 2023

Patent Information (desired but not required for options 1 and 2, mandatory for option 3)						
No.	Status  [granted/ pending]	Country	Granted Patent Number or Application Number (if pending)	Title		
1						
2						
3						